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## **DETAILED ACTION**

## Allowable Subject Matter

- 1. Claims 20-27 are allowed. The following is an examiner's statement of reasons for allowance: the prior art of record fails to teach or fairly suggest the claimed invention.
- Specifically, no teaching or obvious suggestion was found of the 2. limitation " a plate having a first port and a second port extending through a thickness thereof the first port spaced apart from the first lens to receive the first electron beam passing through the first lens, the second port spaced apart from the first port and from the second lens to receive the second electron beam passing through the second lens; a third lens configured to focus the first electron beam on a first position surface and positioned to receive the first electron beam passing through the first port; the fourth lens configured to focus the second electron beam on a second position surface and positioned to receive the second electron beam passing through the second port; and a support configured to engage the semiconductor device and located to receive the first and the second electron beams, at least one of the support and the sources of electrons being movable relative to each other" in combination with the other recited limitations of claim 20.

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3. For example, US Pat No. 6,734,428 issued to Parker et al exemplifies the current state of the art. Parker et al teach multiple electron sources, a plate (250), and individual lens systems for each beam. Parker et al, however, is disqualified as prior art, because the present application's effective filing date is 5-22-1998 based on its continuation status.

- 4. US Pat No 3,715,580 issued to Maekawa et al illustrates the closest prior art, wherein Maekawa et al teach two sources, but fail to teach a single plate having a first and second plate, and the prescribed individual lens systems for each beam.
- 5. Lastly, US Pat No. 5,834,783 issued to Muraki et al is indicative of the field of qualified art, wherein Muraki et al teach multiple sources and individual lens systems, but fail to teach the recited plate and arrangement described in applicant's reply dated 4-6-05. (See pgs.6-7).
- 6. Claims 21-27 are allowed by virtue of their dependency.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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## Conclusion

7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. US Pat No. 6,014,200 issued to Sogard et al; US Pat No.4,390,789 issued to Smith et al; US Pat No. 4,694,178 issued to Harte; US Pat No 6,593,584 issued to Krans et al; US Pat No 6,465,783 issued to Nakasuji; US Pat No 5,557,105 issued to Honji et al; and US Pat No 4,209,702 issued to Shirai et al are considered relevant to the claimed invention.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kalimah Fernandez whose telephone number is 571-272-2470. The examiner can normally be reached on Mon-Tues 6:30-3:30; Wed-Thurs 8-5 and Fri.9am-6 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John R. Lee can be reached on 571-272-2477. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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KF ·

SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800